

# Particle Sources

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# Many Many Particle Sources

## Species

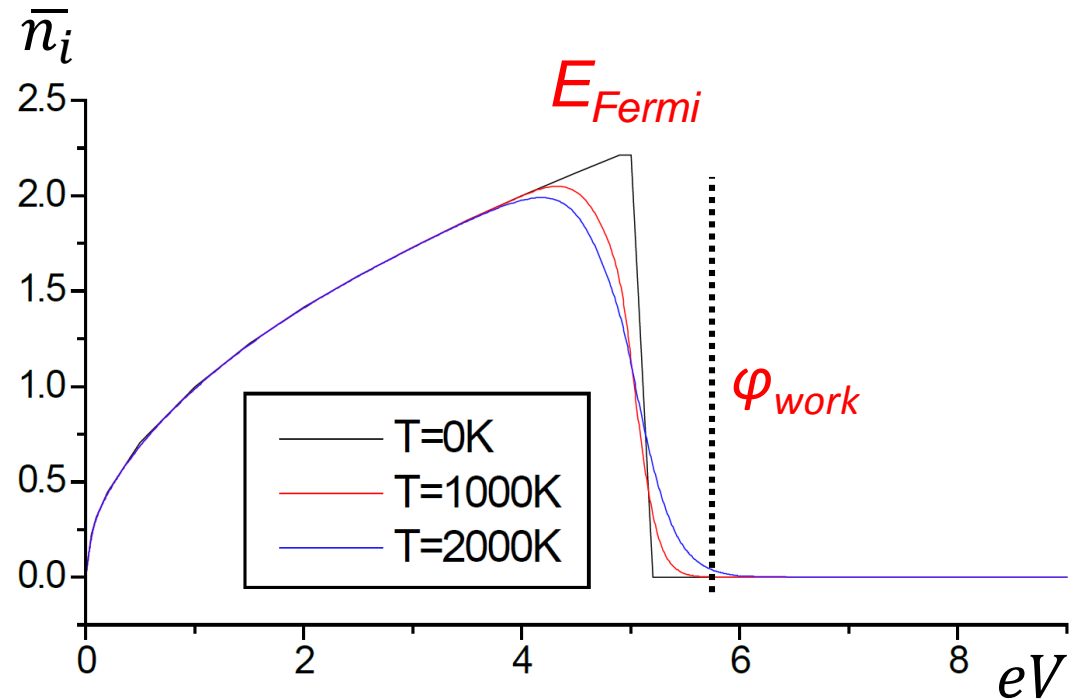
- Electron
- Proton
- <sup>1+</sup> Light Ion
- <sup>4+</sup> Heavy Ion
- Negative Ion
- <sup>34+</sup> High Charge State
- Radioactive
- Spin-Polarised
- Neutral
- Muon
- Exotic

## Technique

- Filament
- Photocathode
- Arc Plasma
- Laser
- Microwave
- RF
- Cyclotron-Resonance
- Duopigatron
- Duoplasmatron
- ...

# Fermi-Stats. & Work Function

- Fermi level,  $E_{Fermi}$  is kinetic energy of electron in highest occupied state
- Work-function,  $\varphi_{work}$  is energy input to release an electron from the surface (basis of photoelectric effect)
- Higher temperature,  $T$  smears out the Fermi level
- Some electrons may cross work-function and escape
- Integrating the number of available released electrons gives current density,  $J$
- To get a lot of current, need high  $T$  and a material with a high  $A$  and low  $\varphi_{work}$

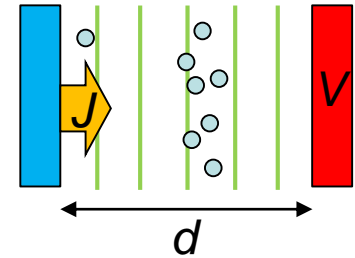


$$J = AT^2 e^{\left(\frac{-\varphi_{work}}{k_B T}\right)}$$

Richardson-Dushman equation

# Child-Langmuir Law

- Want the released particles to go somewhere
- Apply potential difference to accelerate into a beam
- E-field of already-emitted particles shields the cathode from the accelerating E-field: **space-charge-limited flow**
- Cannot accelerate an arbitrarily high number of particles
- Can calculate the **extractable** current density:



Continuity eqn.

$$J = \rho \dot{x}$$

Kinetic energy

$$\frac{1}{2} m \dot{x}^2 = -q\phi$$

Poisson eqn.

$$\frac{d^2 \phi}{dx^2} = -\frac{\rho}{\epsilon_0}$$

$$\frac{d^2 \phi}{dx^2} = K \phi^{-1/2}$$

where:  $K = \sqrt{\frac{m}{2q} \frac{J}{\epsilon_0}}$

# Child-Langmuir Law (cont'd.)

$$\frac{d^2\varphi}{dx^2} = K\varphi^{-1/2} \quad \text{Substitute: } \varphi' = \frac{d\varphi}{dx} \quad \text{Then: } \varphi' d\varphi' = K\varphi^{-1/2} d\varphi$$

$$\text{Integration gives: } \varphi'^2 = 4K\varphi^{1/2} \quad \text{So: } \varphi' = \frac{d\varphi}{dx} = 2\sqrt{K}\varphi^{1/4}$$

$$\text{Rearrange and integrate again: } 2\sqrt{K}x = \frac{4}{3}\varphi^{3/4} \quad \text{Bound. cond.: } \varphi_{(x=d)} = V$$
$$\text{So: } K = \frac{4}{9} \frac{V^{3/2}}{d^2}$$

$$\text{But from the previous slide: } K = \sqrt{\frac{m}{2q}} \frac{J}{\varepsilon_0} \quad \text{Therefore:}$$

$$J = \frac{4}{9} \varepsilon_0 \sqrt{\frac{2q}{m}} \frac{V^{3/2}}{d^2}$$

This Child-Langmuir “ $V^{3/2}$ ” Law says that the extractable current density of a particle source depends **ONLY** on the voltage and electrode gap

# Child-Langmuir Law (cont'd.)

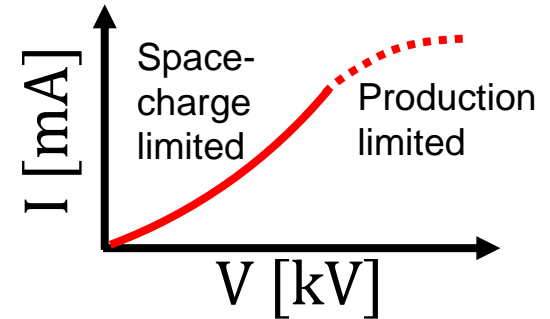
$$J = \frac{4}{9} \epsilon_0 \sqrt{\frac{2q}{m}} \frac{V^{3/2}}{d^2}$$

Total extracted current,  $I$  from an area,  $A$  is thus:

where:

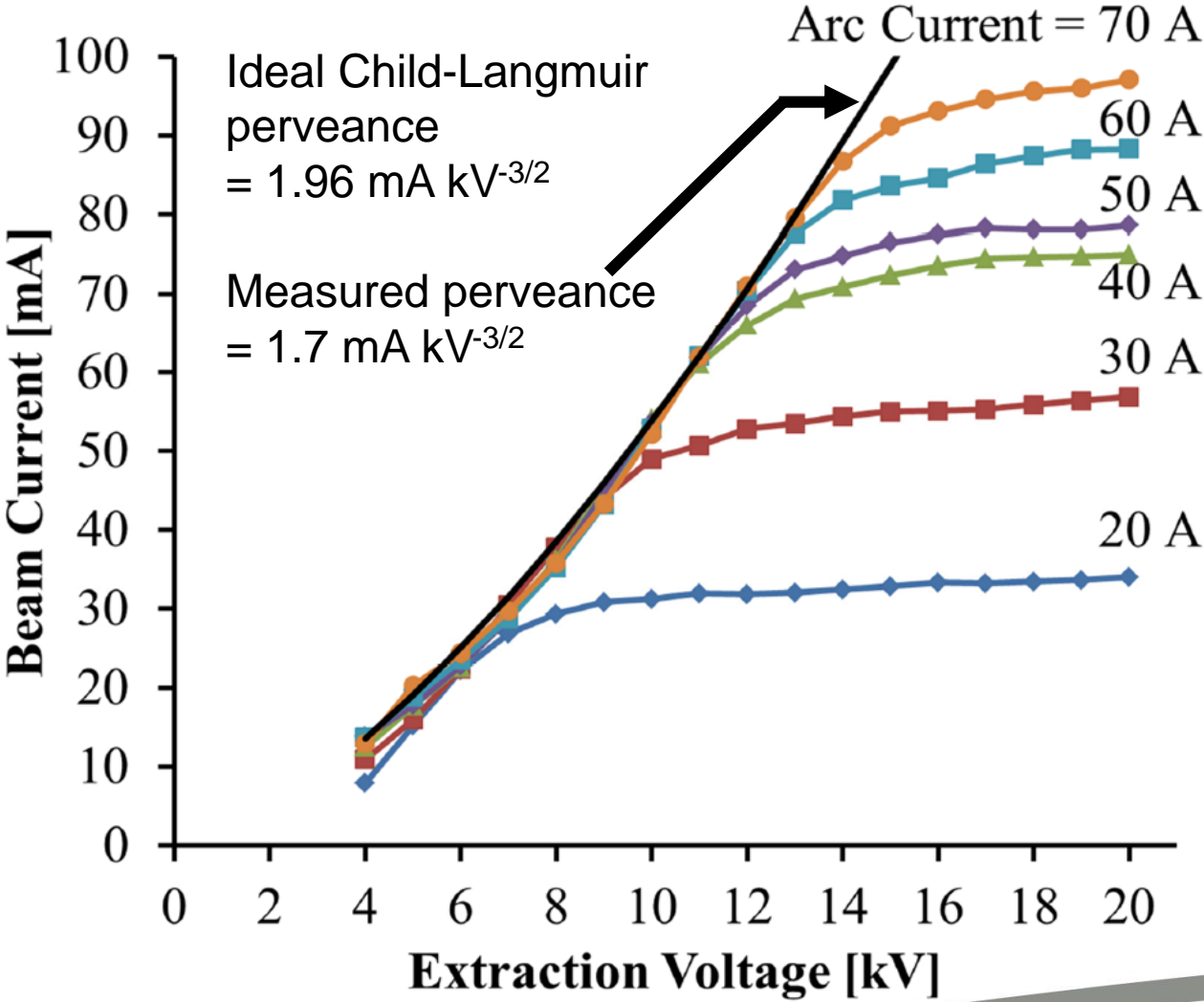
$$P = \frac{4}{9} \epsilon_0 \sqrt{\frac{2q}{m}} \frac{A}{d^2}$$

$$I = JA = PV^{3/2}$$



- This  $P$  is the **perveance**: depends only on source geometry
- Real measured beam perveance always lower than this
- Assumes infinite, thin, plane electrodes (usually not true)
- Assumes particles starting with zero velocity
- $V^{3/2}$  law only holds if particle source can deliver the current

# Perveance Measurement



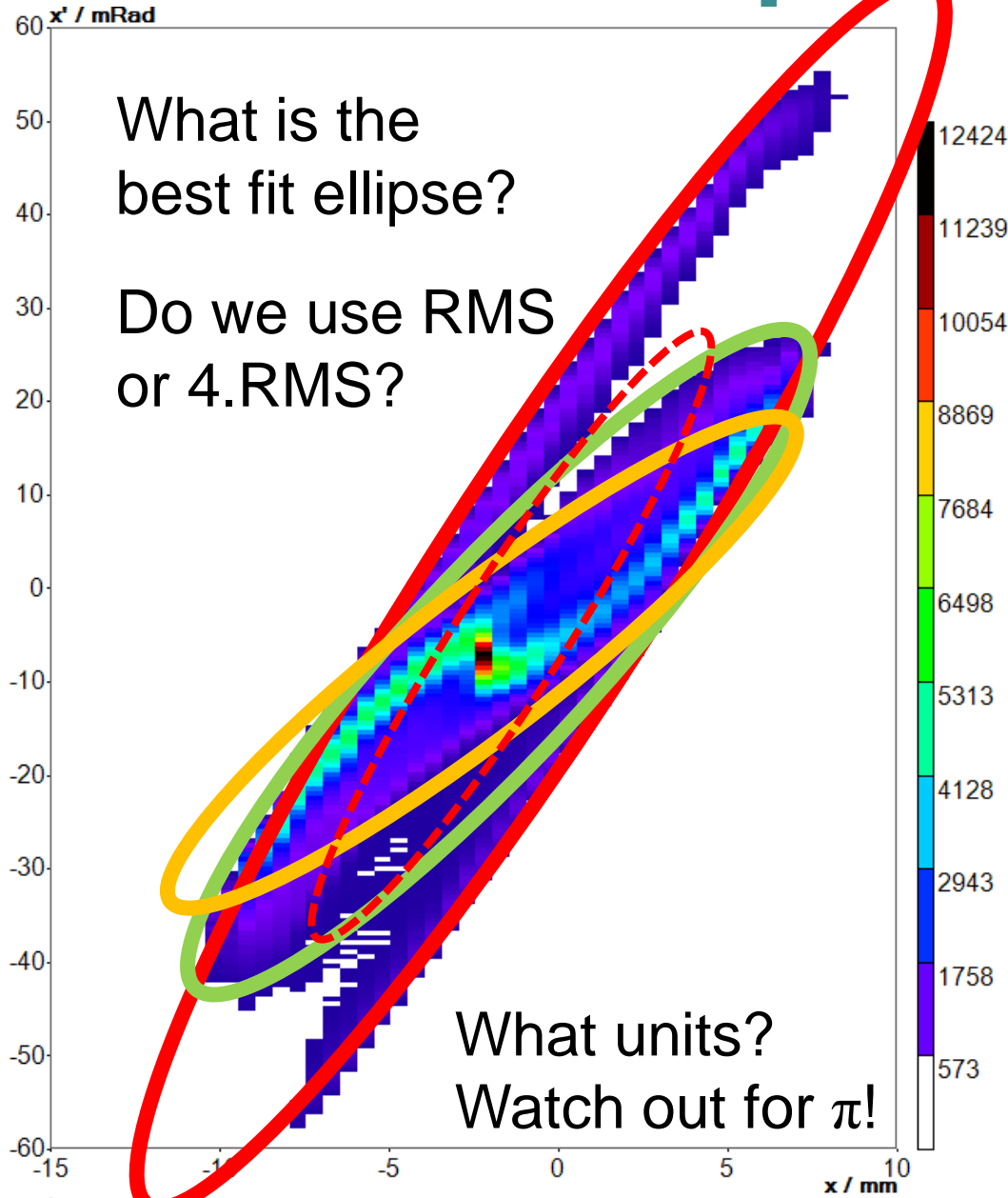
# Emittance

- Quality of beam just as important as quantity
  - Emittance affects machine luminosity and beam-loss
  - Want beam emittance < machine acceptance
- Particles occupy 6-dimensional phase space ( $x, P_x, y, P_y, z, P_z$ )
- Practical measurements use position-angle ('trace') space
- Emittance scan can tell immediately how a beam is focused
- Also shows up important aberrations (not just pure ellipses)





# Emittance Ellipses and Pitfalls



Ellipse defined by:

$$\gamma x^2 + 2\alpha x x' + \beta x'^2 = \epsilon_x$$

where:  $\beta\gamma - \alpha^2 = 1$   
are the Twiss parameters

For real, non-elliptical data sets, calculate 4.RMS emittance statistically:

$$\epsilon_{4.rms} = 4\sqrt{\langle x^2 \rangle \langle x'^2 \rangle - \langle x x' \rangle^2}$$

Units usually given in  $[\pi \text{ mm mrad}]$ , but varies

# High Voltage Considerations

$$F = q(E + v \times B)$$

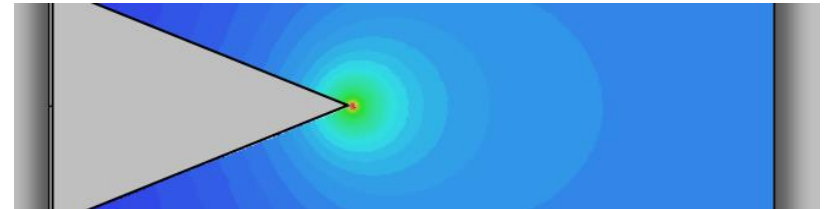
Particle sources have very low beam energy:

- ~~Magnetic focusing~~
- ~~Magnetic deflection~~
- ~~RF acceleration~~
- ~~Relativistic~~
- ~~Ample space~~
- High space-charge
- Dirty vacuum
- Sensitive diagnostics

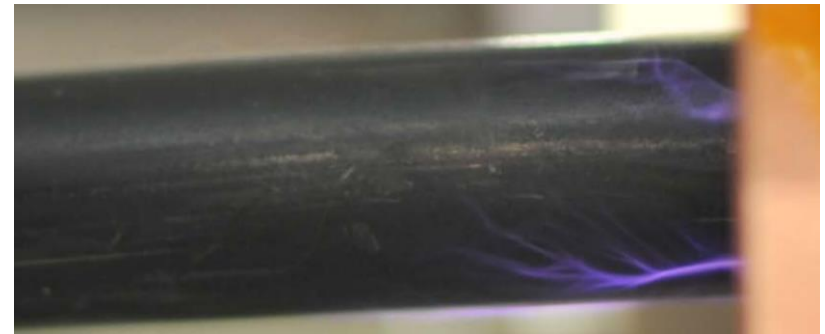
HV is the only option, BUT:



Must protect insulator triple junctions



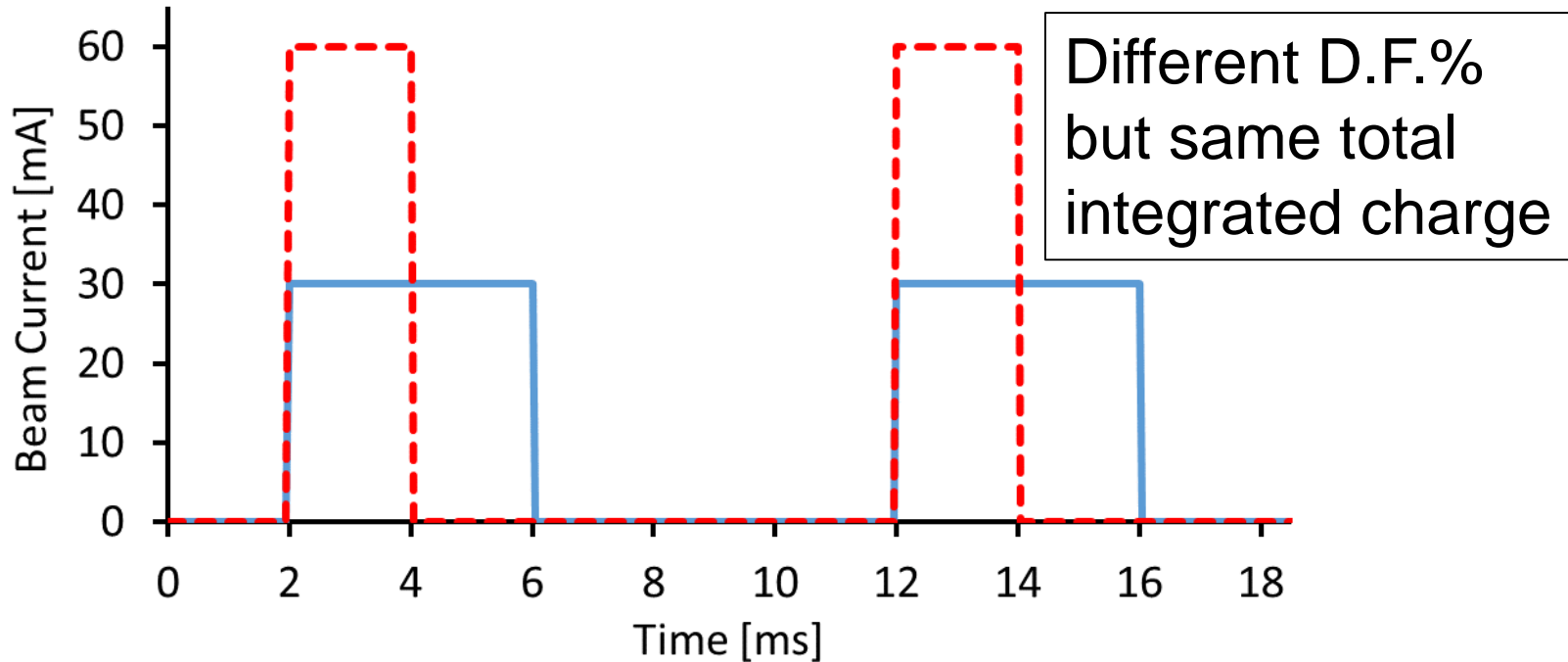
Must avoid points in E-field regions



Must ensure proper cable terminations

# Timing in Pulsed Sources

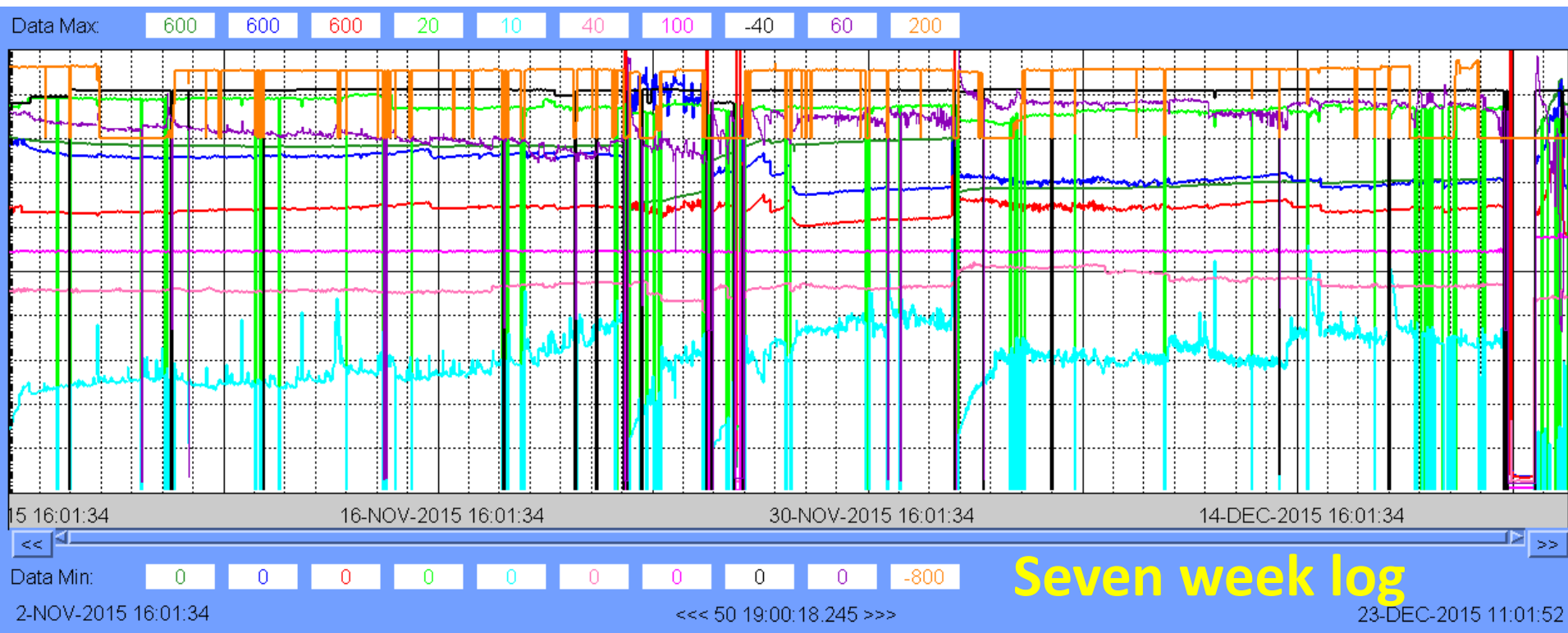
- Usually only need beam a fraction of the time
- However, more difficult to make pulsed power supplies



**Duty Factor = Pulse Length x Repetition Rate**

e.g. ISIS:  $200 \mu\text{s} \times 50 \text{ Hz} = 1\% \text{ Duty Factor}$

# Reliability and Stability



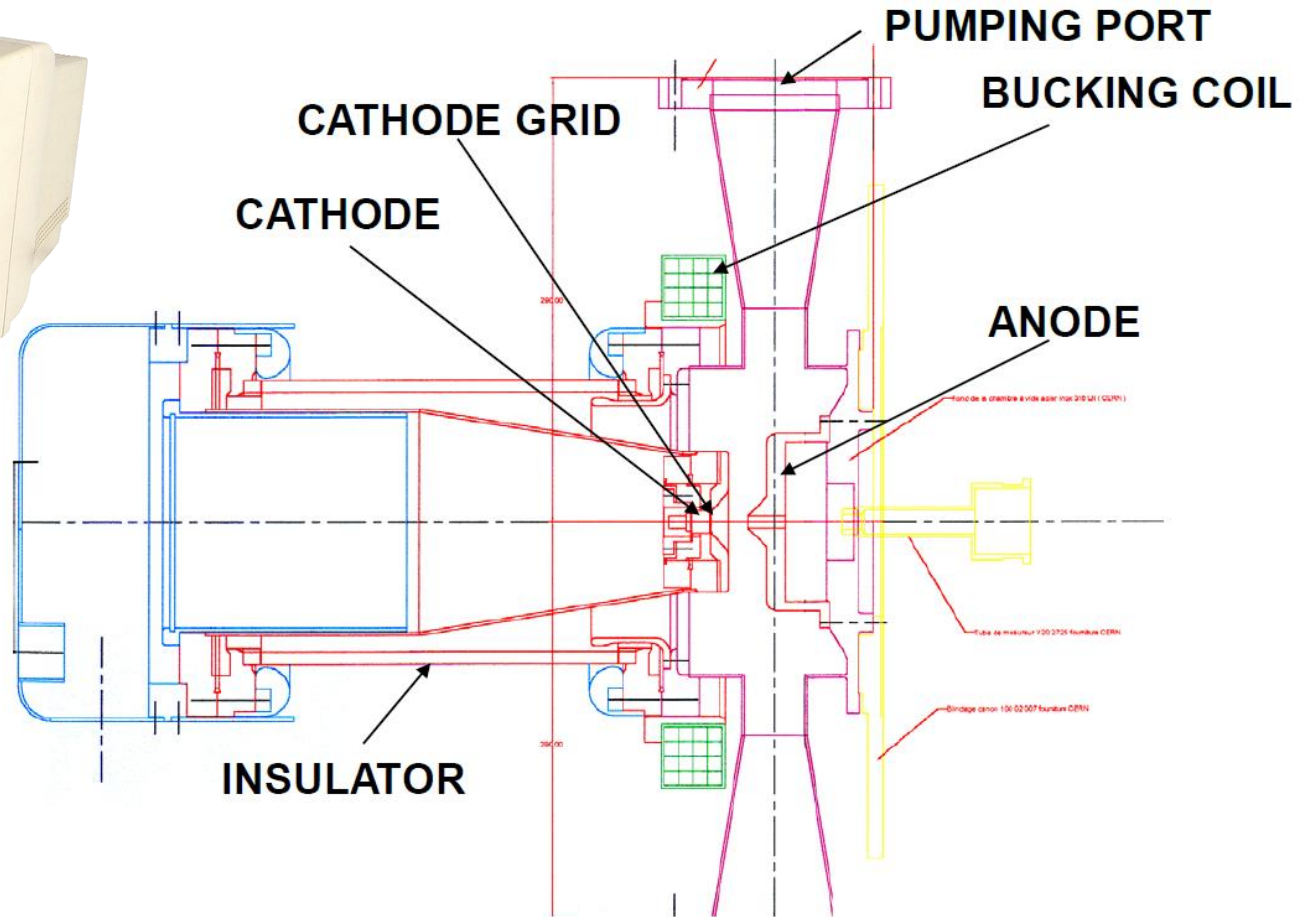
#	Y source	Color	Value	Time	Units	Cursor Value
1	IRFQ::CATHODE:READ_TEMP	Green	----	-----		-----
2	IRFQ::ANODE:READ_TEMP	Blue	----	-----		-----
3	IRFQ::SOURCE_BODY:READ_TEMP	Red	----	-----		-----
4	IRFQ::EXT:READ_VOLTS	Cyan	----	-----		-----
5	IRFQ::EXT:READ_CURRENT	Magenta	----	-----		-----
6	IRFQ::H2_GAS:READ_FLOW	Pink	----	-----		-----
7	IRFQ::ARC_AC:READ_CURRENT	Black	----	-----		-----
8	IRFQ::PLATFORM:READ_VOLTS	Purple	----	-----		-----
9	IRFQ::IS_TOROID:READ_CURRENT	Orange	----	-----		-----
10	LOCAL::BEAM:TARGET	Black	----	-----		-----

Archive: CON\_ROOT:[data.logging.vlog-irfq]irfq\_vlog.varc

# Summary of Fundamentals

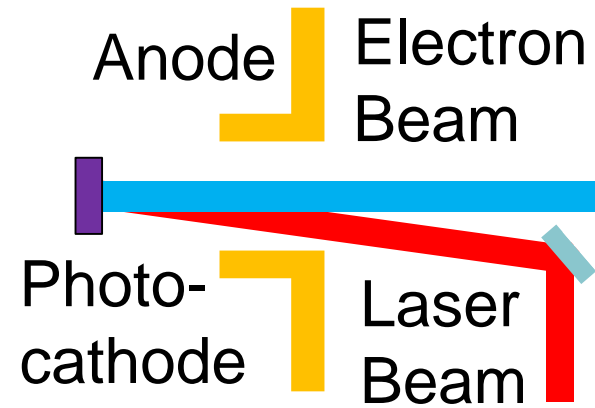
- Electrons released from **hot surfaces**
- Lower **work-function** materials release more electrons
- Space-charge limit to amount of **extractable current**
- Extraction systems described by their **perveance**
- Particle beams described by their **emittance**
- Many ways to define emittance and its units: be **careful**
- Must consider **high voltage** engineering requirements
- Usually need specialist **pulsed** power supplies
- **Reliability** dominates all other performance goals
- Now we can move onto real particle sources...

# Thermionic Electron Gun



W dispenser cathode  
with impregnated  
 $\text{BaO}:\text{CaO}:\text{Al}_2\text{O}_3$

# Photocathode Electron Guns



Material	Type	$(E_{\text{gap}} + E_{\text{Aff}})^*$ or $\phi_{\text{work}}$ [eV]	$\lambda$ [nm]	Q.E. $\$$
W	Metal	4.5	375	$10^{-6}$
W:Th	Metal	2.6	477	$10^{-5}$
Cs	Metal	1.81	685	$10^{-3}$
LaB <sub>6</sub>	Ceramic	2.6	477	$10^{-6}$
GaAs:Cs	Semi-cond.	2.3	532	$\sim 0.10$ $\&$
Cs <sub>2</sub> Te	Semi-cond.	3.5	350	0.12
K <sub>2</sub> CsSb	Semi-cond.	2.1	590	0.29

\* In semi-conductors, the equivalent to work function  $\phi_{\text{work}}$  is (band-gap + electron affinity)

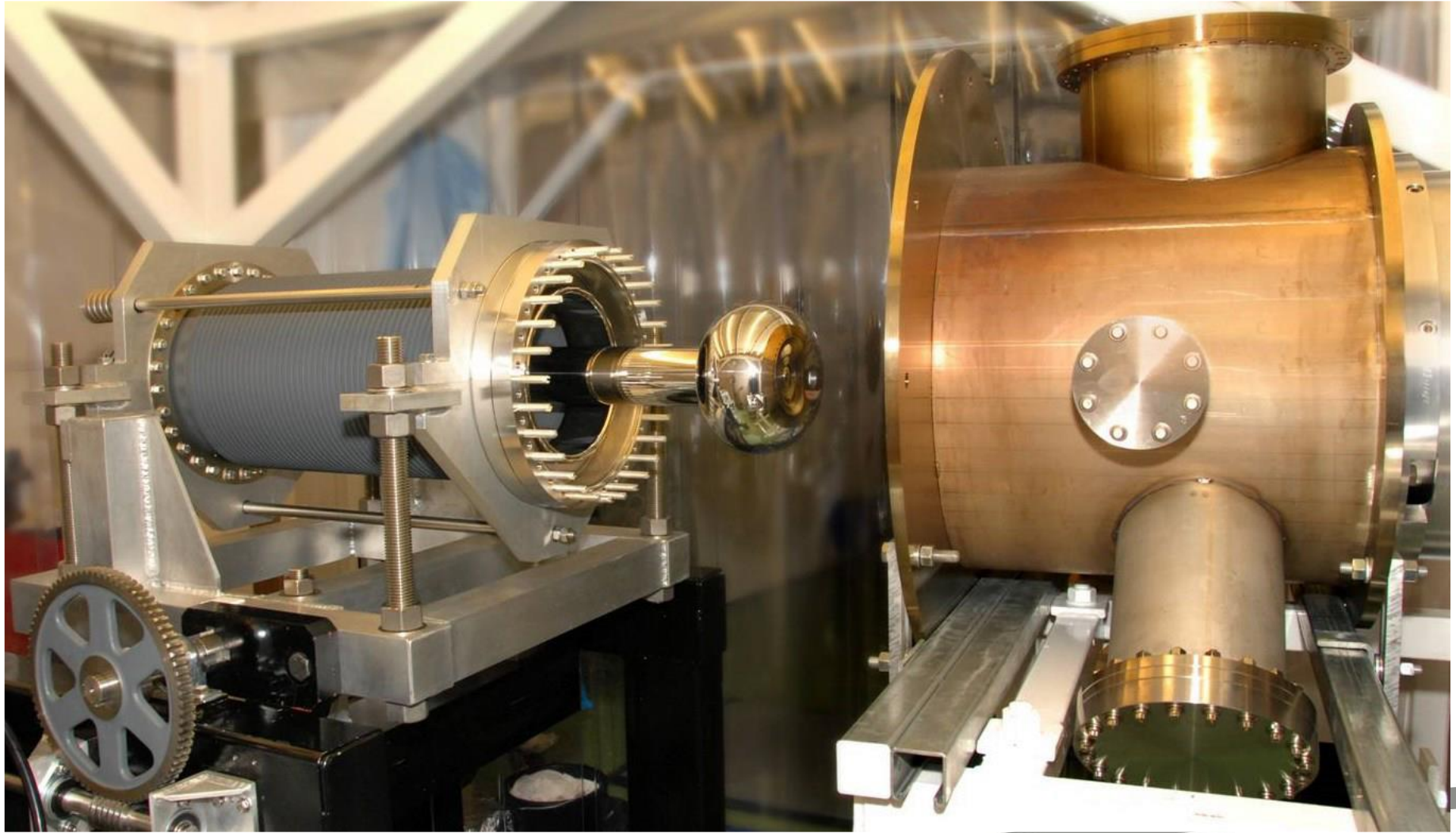
$\$$  Q.E. = Quantum efficiency = Electrons/Photon

$\&$  Vacuum-dependent

- Use low work function cathode
- Raise temperature
- Fire laser onto it
- Accelerate e-beam
- Bunch timing set by laser pulses

# DC Photocathode Gun

ALICE @ DL

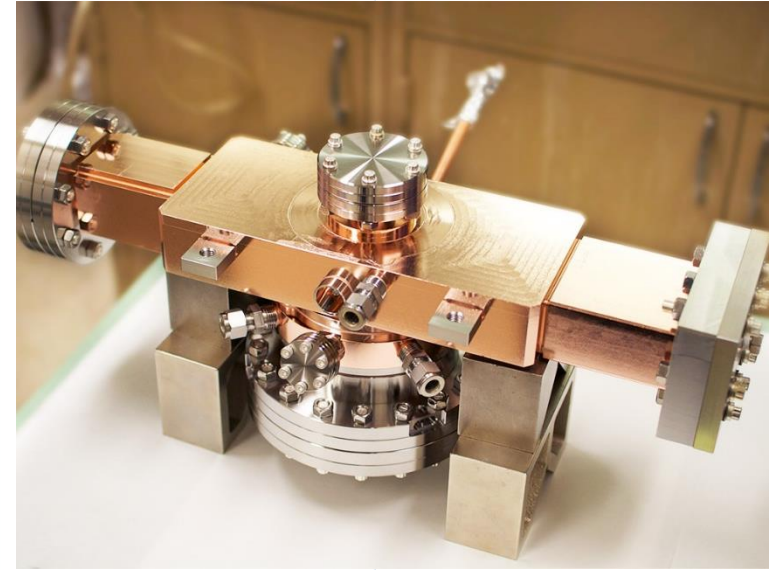
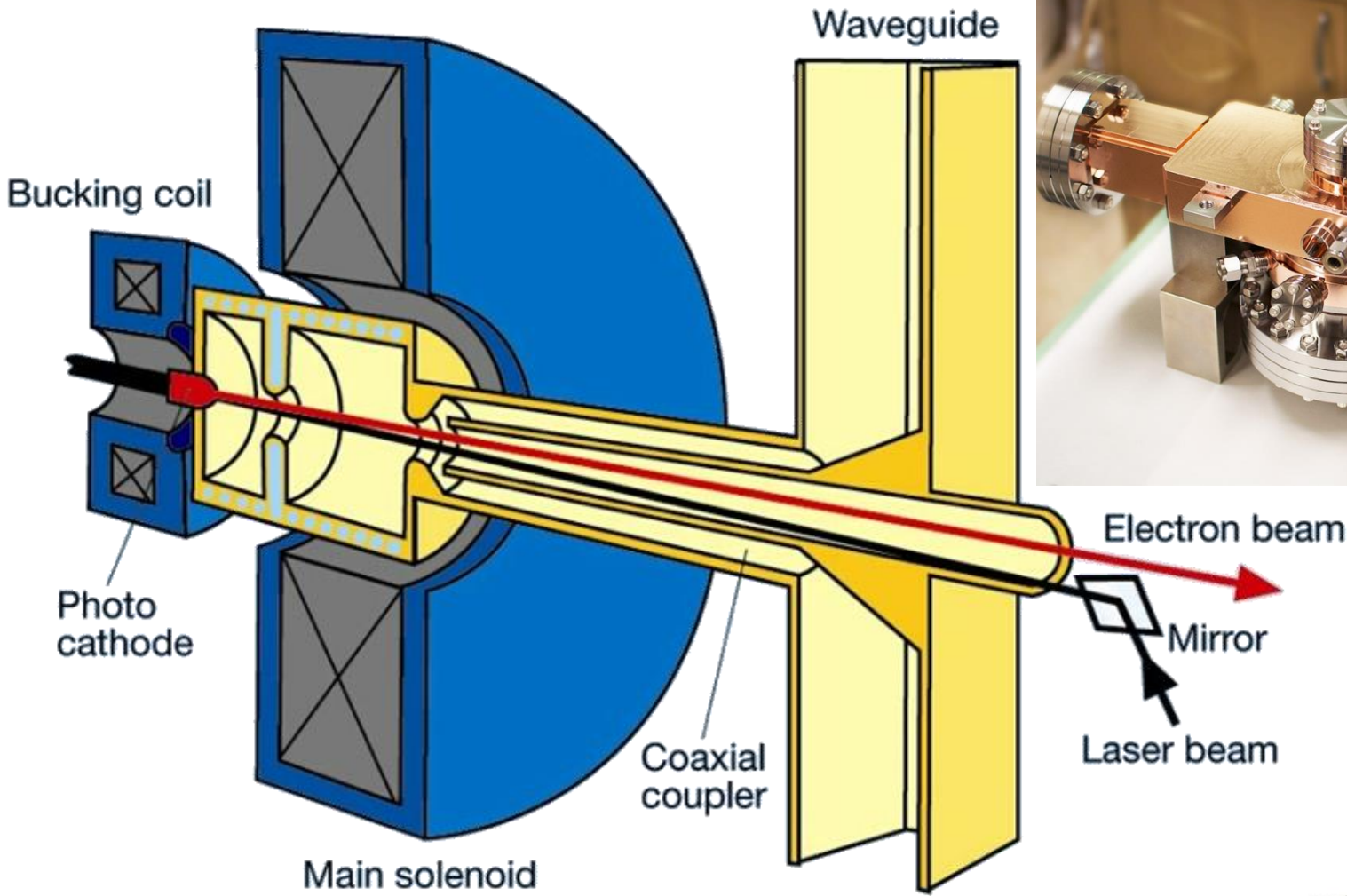


350 kV DC, 80 pC bunch, GaAs:Cs



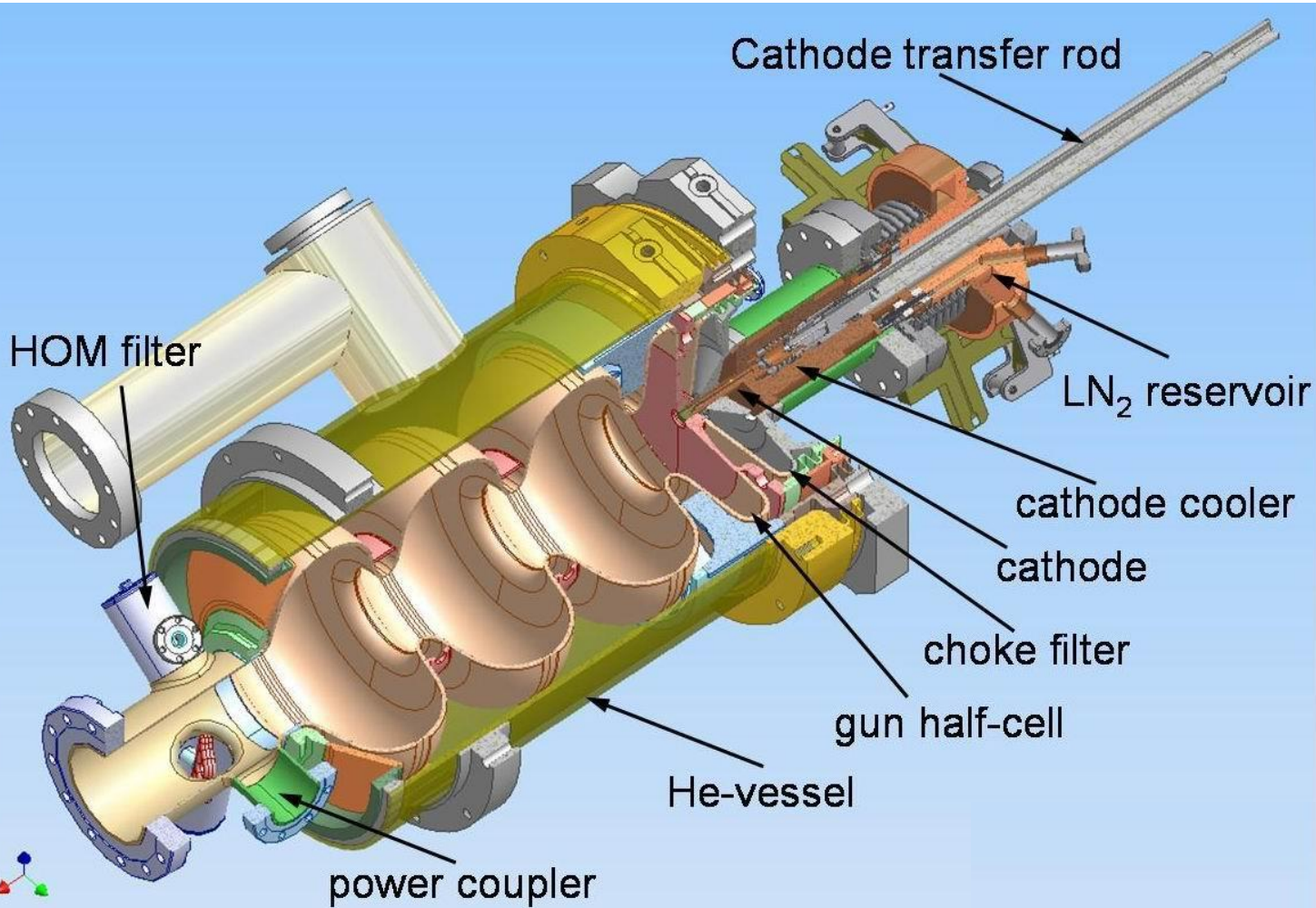
# RF Photocathode Gun

FERMI2 @ Trieste



3 GHz RF  
50 Hz laser  
Q.E.  $\sim 3 \times 10^{-5}$   
500 pC bunch  
5.1 MeV beam

# Superconducting RF Gun SRF2 @ ELBE




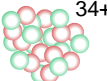
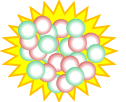



Cs<sub>2</sub>Te cathode  
1.3 GHz CW RF  
13 MHz UV laser  
200 pC bunch  
4.5 MeV beam

Main issue with all photoinjectors using Cs<sub>2</sub>Te cathodes is the need to replace the cathode after ~100 hours

# Most are Plasma-Based Sources

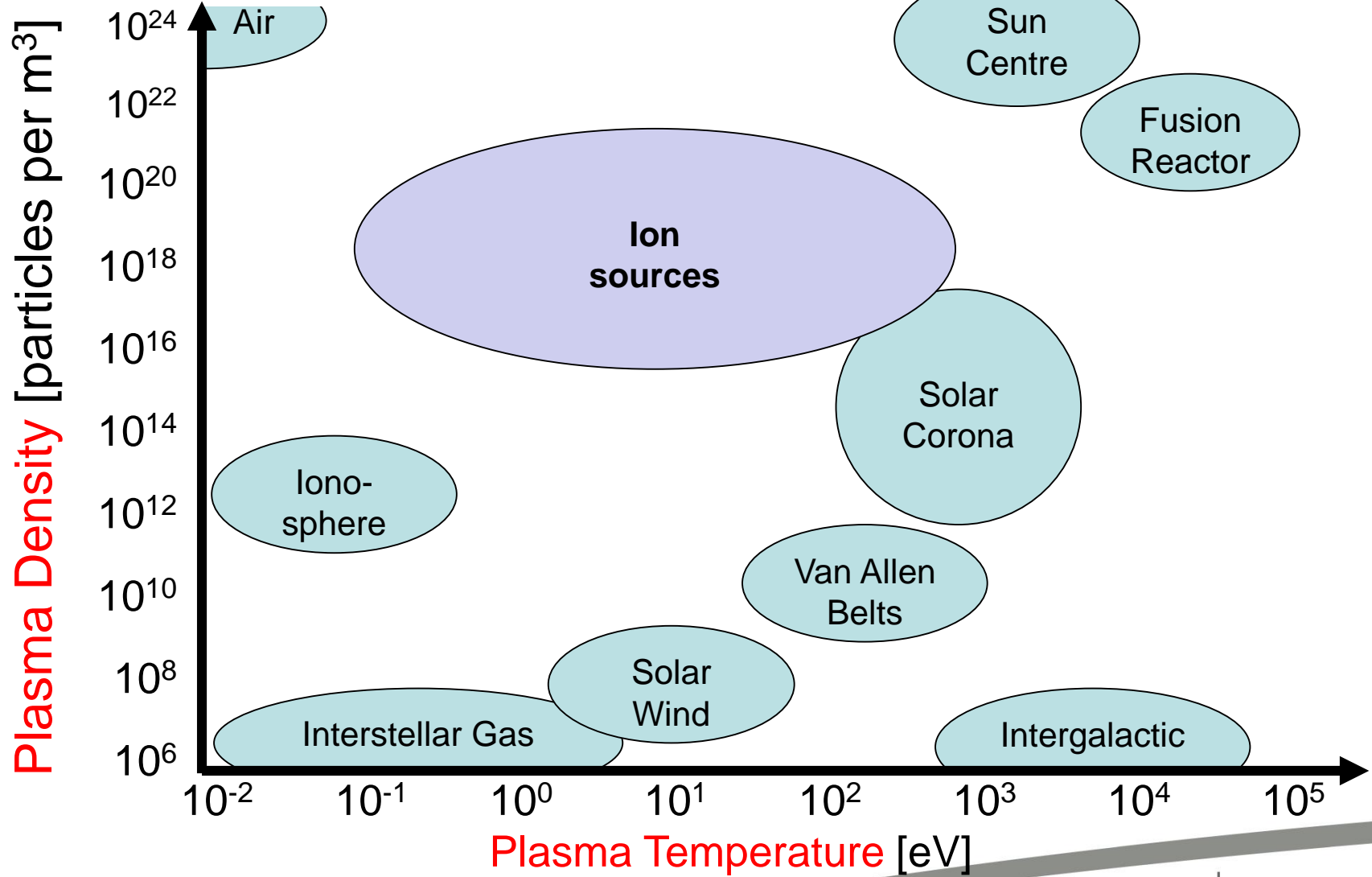
## Species

- Electron
- Proton
-  <sup>1+</sup> Light Ion
-  <sup>4+</sup> Heavy Ion
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-  Radioactive
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## Technique

- Filament
- Photocathode
- Arc Plasma
- Laser
- Microwave
- RF
- Cyclotron-Resonance
- Duopigatron
- Duoplasmatron
- ...

# Plasma Parameters



1 eV  $\approx$  11,600 K

# Plasma Fundamentals

- Maxwell-Boltzmann **temperature-dependent velocity**:

$$f(\vec{v}) = \frac{n}{(\sqrt{2\pi} v_T)^3} e^{(-v^2/2\langle v \rangle^2)} \quad \text{with} \quad \langle v \rangle = \sqrt{\frac{k_B T}{m}}$$

- **Debye length** is distance charge perturbations can exist:

$$\lambda_D = \sqrt{\frac{\epsilon_0 k_B T}{n_e e^2}}$$

- Electrons react to perturbations at the **plasma frequency**:

$$\omega_p = \sqrt{\frac{n_e e^2}{\epsilon_0 m_e}}$$

# Plasma Fundamentals

- Particle **collision frequency** depends on cross-section:

$$\langle \omega_{en} \rangle = 2\pi n_n \sigma_{en} \langle v_e \rangle$$

- With a **mean free path** between collisions:

$$\lambda_f = \frac{1}{n_n \sigma_{en}}$$

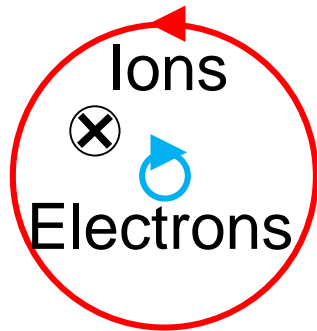
- Electron impact ionisation examples:



- To ionise efficiently, need plasma **confinement**, usually in the form of magnetic fields

# Plasma Fundamentals

- Charged particles confined transversely in a uniform B-field

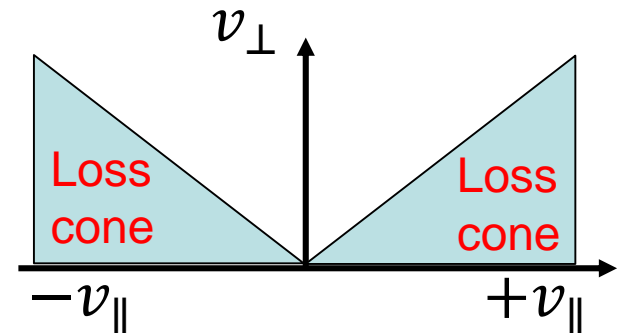


Larmor frequency:  $\omega_L = \frac{eB}{m}$   
(a.k.a. **cyclotron**)

Larmor radius:  $r_L = \frac{v_{\perp}}{\omega_L}$

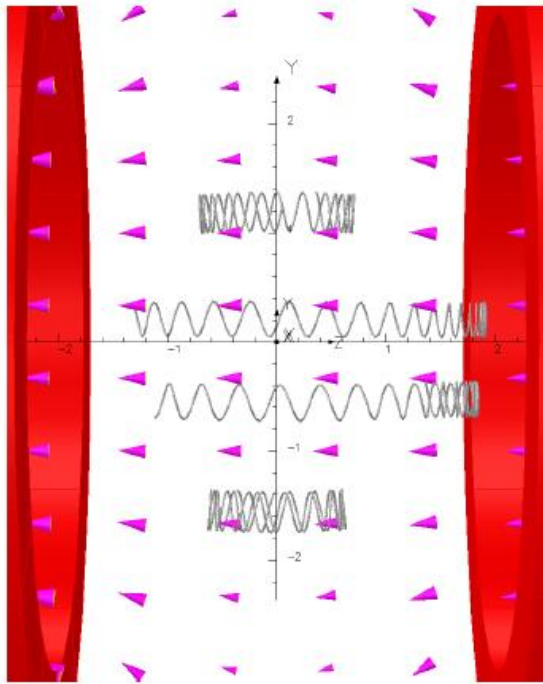
- If particles also have  $v_{\parallel}$  and B-field is increasing into screen, get longitudinal **magnetic mirror** confinement with:

$$v_{\parallel}/v_{\perp} < \sqrt{\left(B_{max}/B_{min} - 1\right)}$$

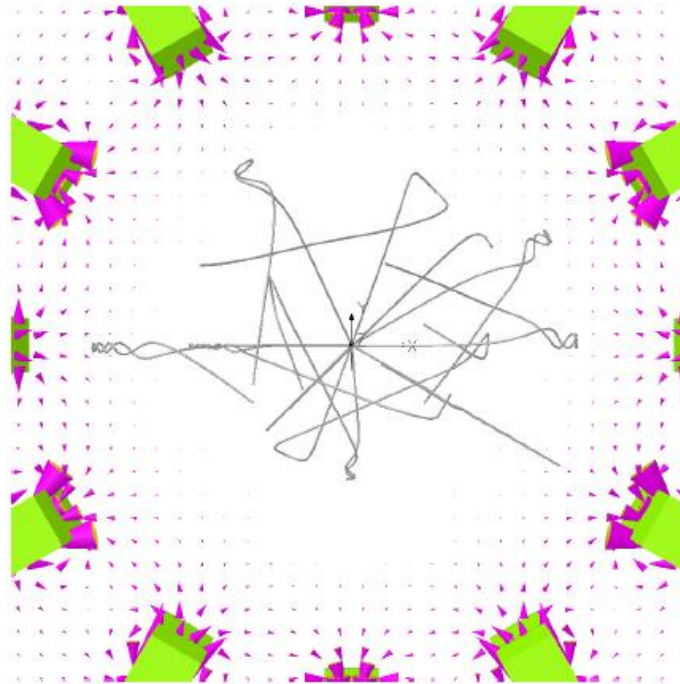


- Mirror both ends  $\rightarrow$  **magnetic bottle**
- Also ExB, gradB, curvature & diffusion drifts

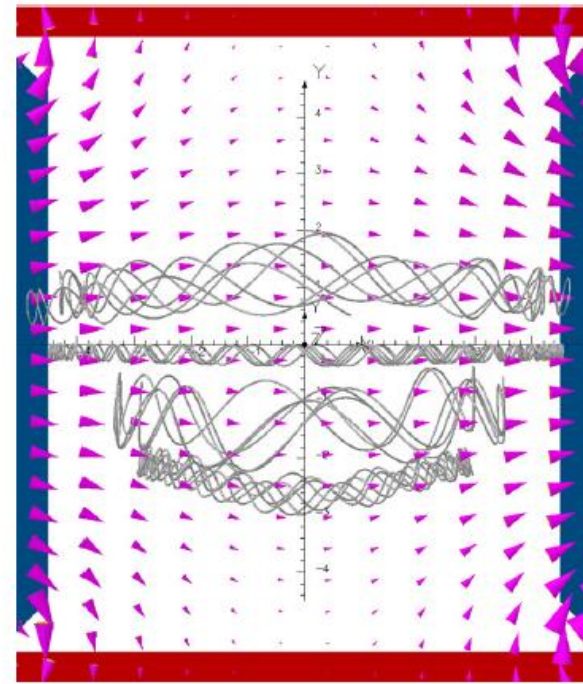
# Plasma Confinement Techniques



**Solenoid bottle**  
(often combined with  
hexapole cusp)



**Multicusp 'bucket'**  
of dipoles in  
checkerboard pattern



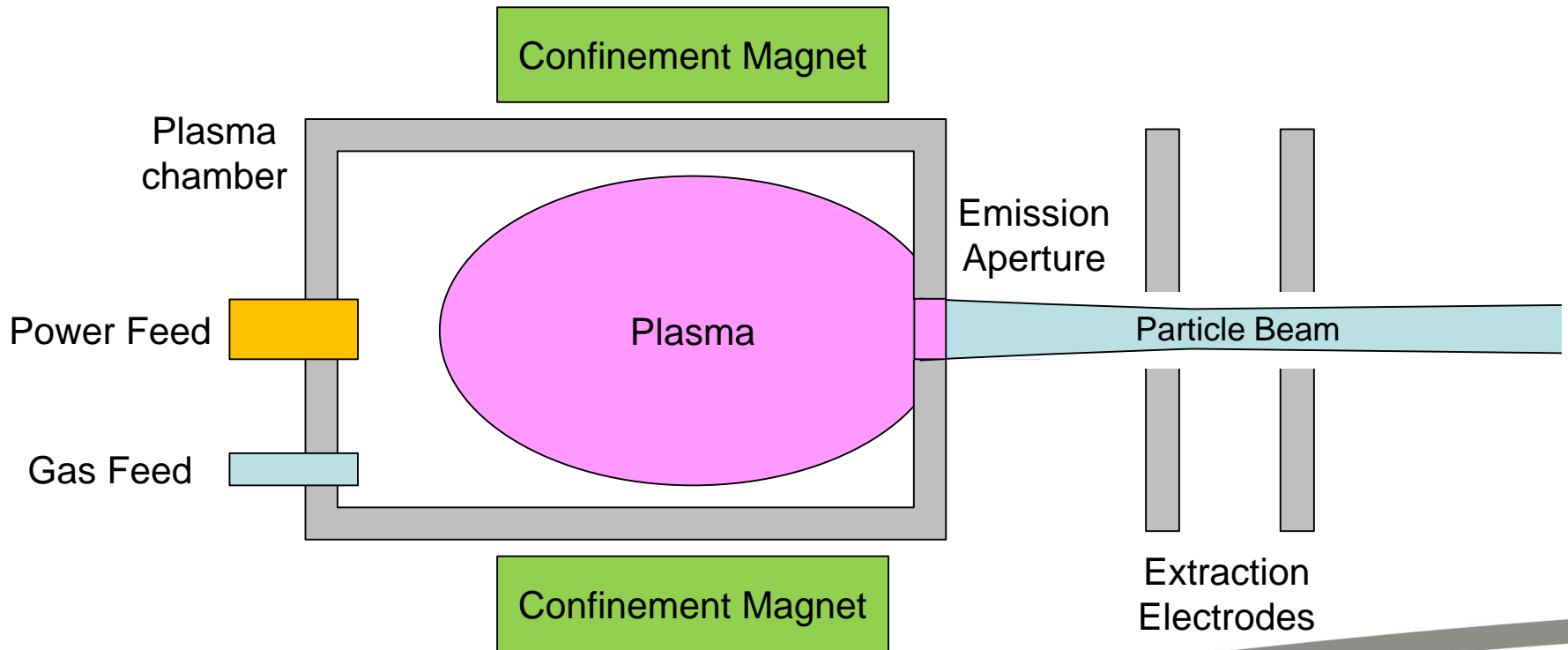
**Dipole magnet,**  
parallel cathodes  
and anode 'window'



# The Typical Ion Source

Every ion source basically consists of two parts:

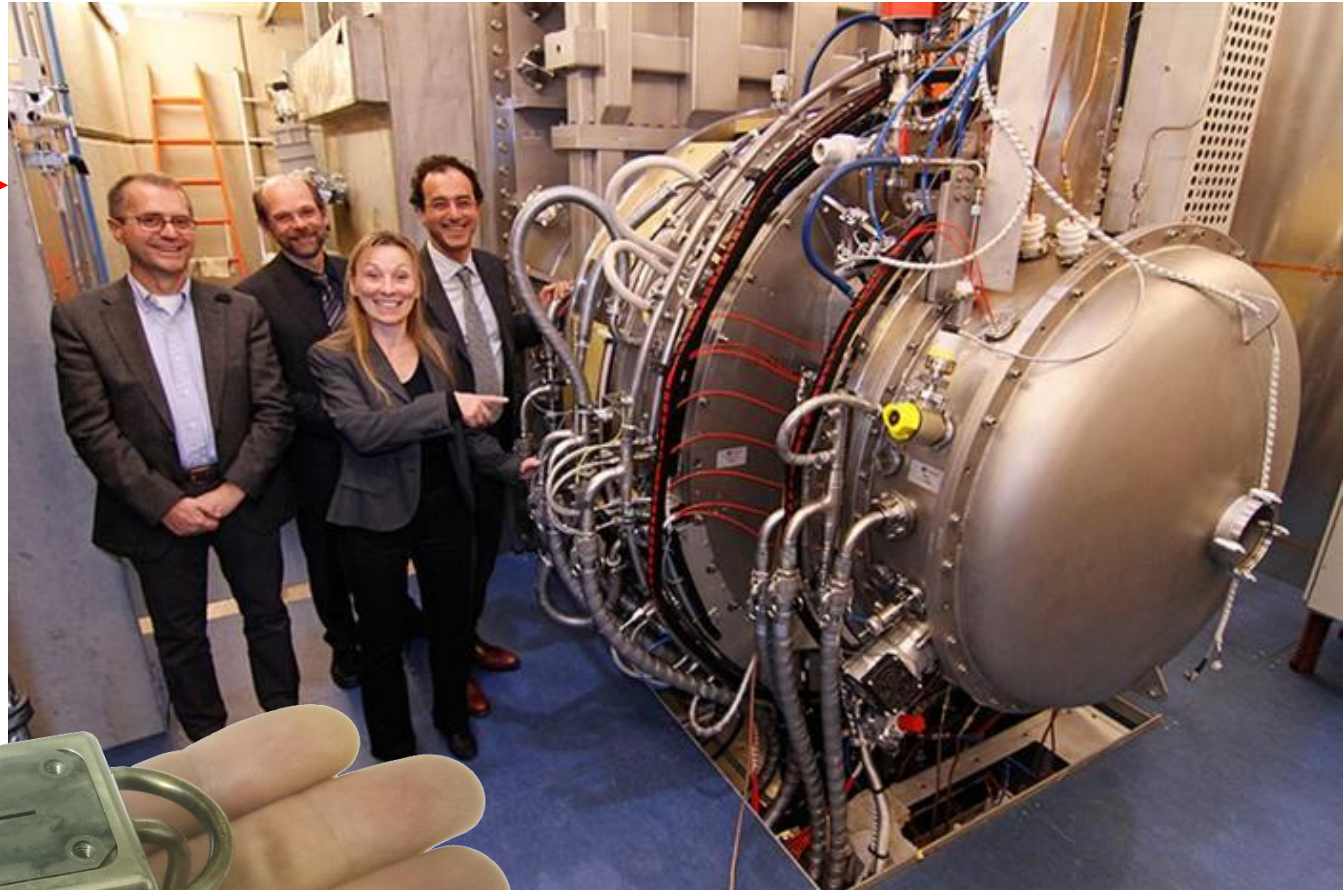
1. **Ion production** inside a plasma
2. **Beam extraction** from the plasma



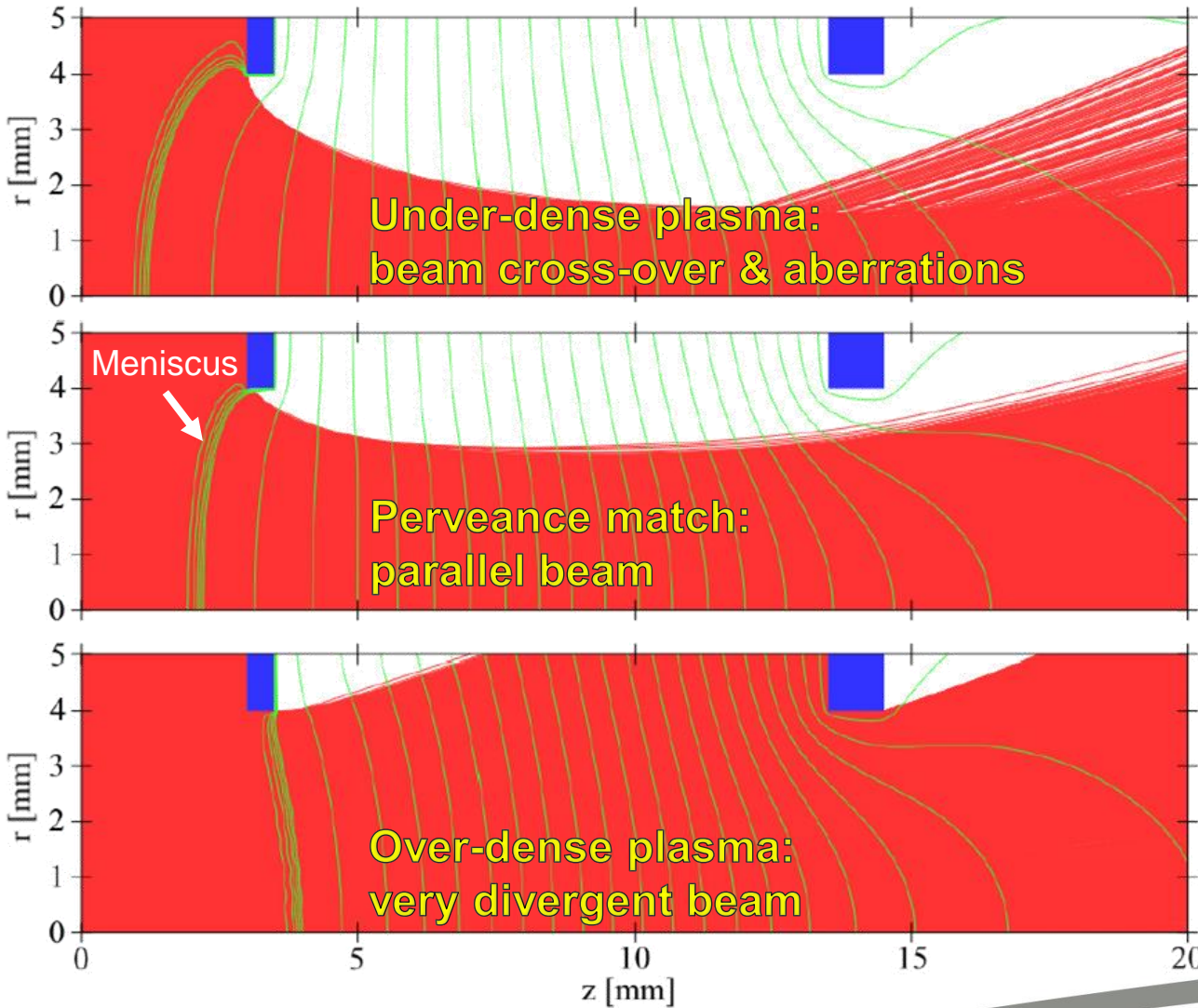
# No 'Typical' Ion Sources!

'ELISE' ITER  
Demonstration →  
H<sup>-</sup> Source

ISIS  
H<sup>-</sup> Source



# Beam Extraction



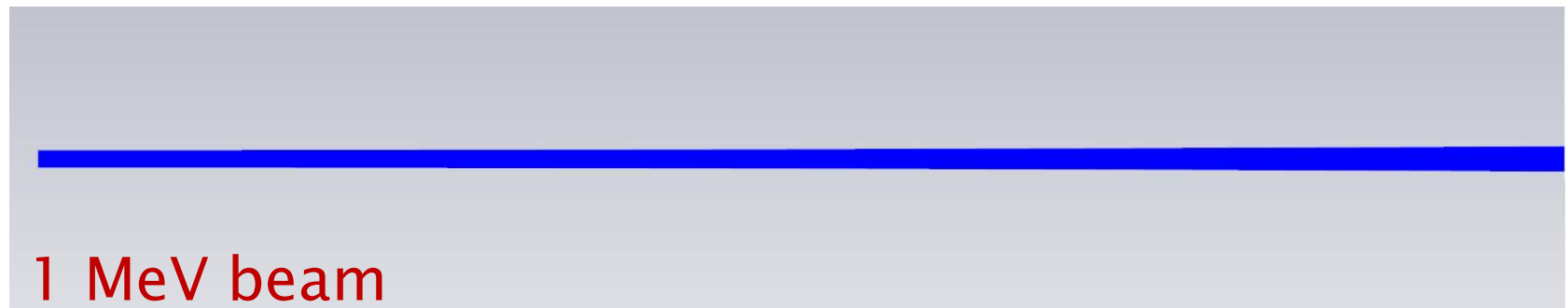
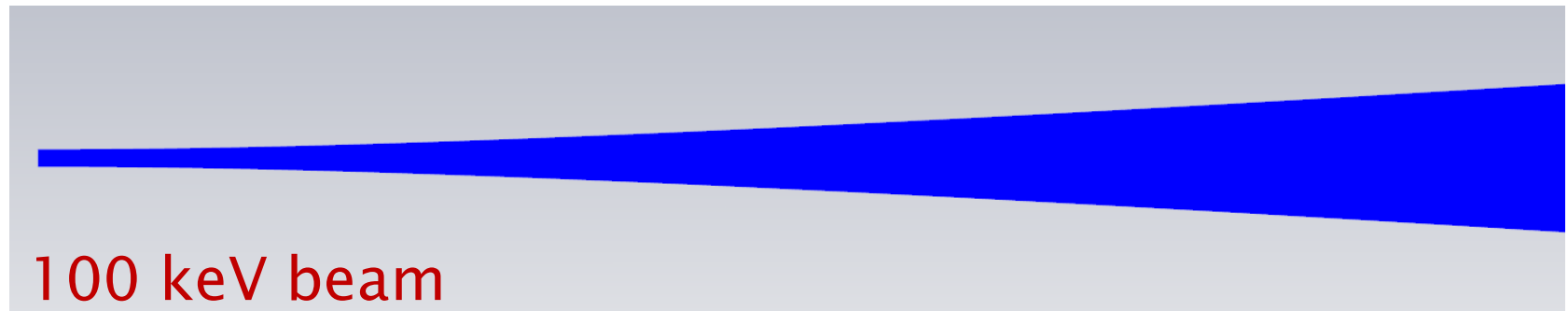
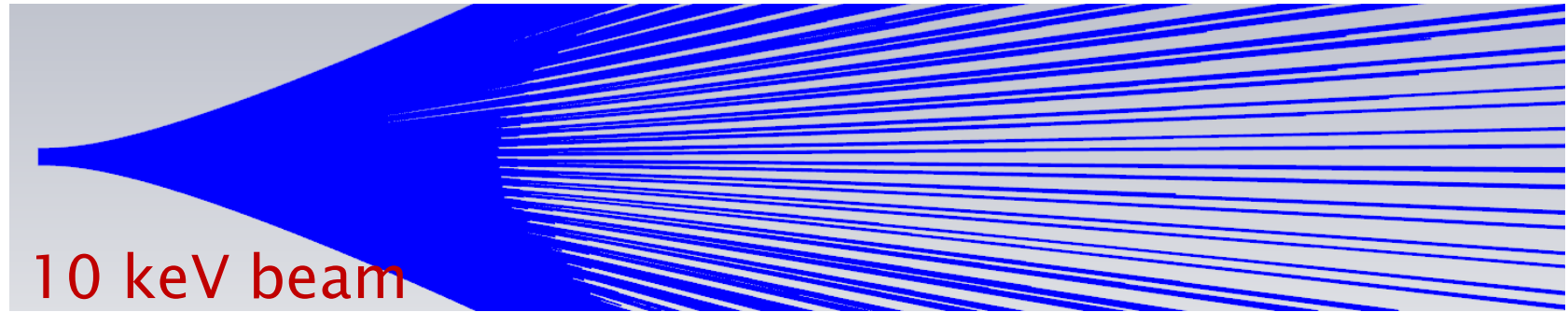
Particle dynamics at emission aperture **defines** the beam performance throughout entire accelerator: crucial!

**Plasma meniscus** is notional 'boundary' where beam originates

Meniscus sets beam **current, emittance and focussing**. Shape varied by plasma density, extraction voltage and electrode geometry

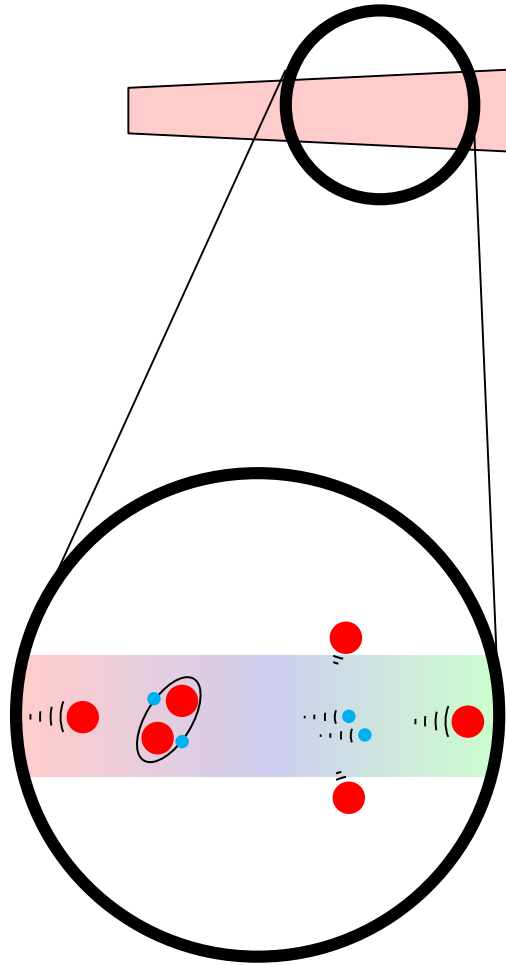
# Space Charge

50mA proton beam, 5mm initial radius, drifting 1 m

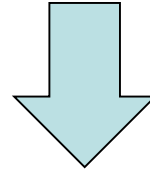


**CONCLUSION: Need to focus and accelerate low energy beams hard**

# Space Charge Compensation



Space charge increases beam size



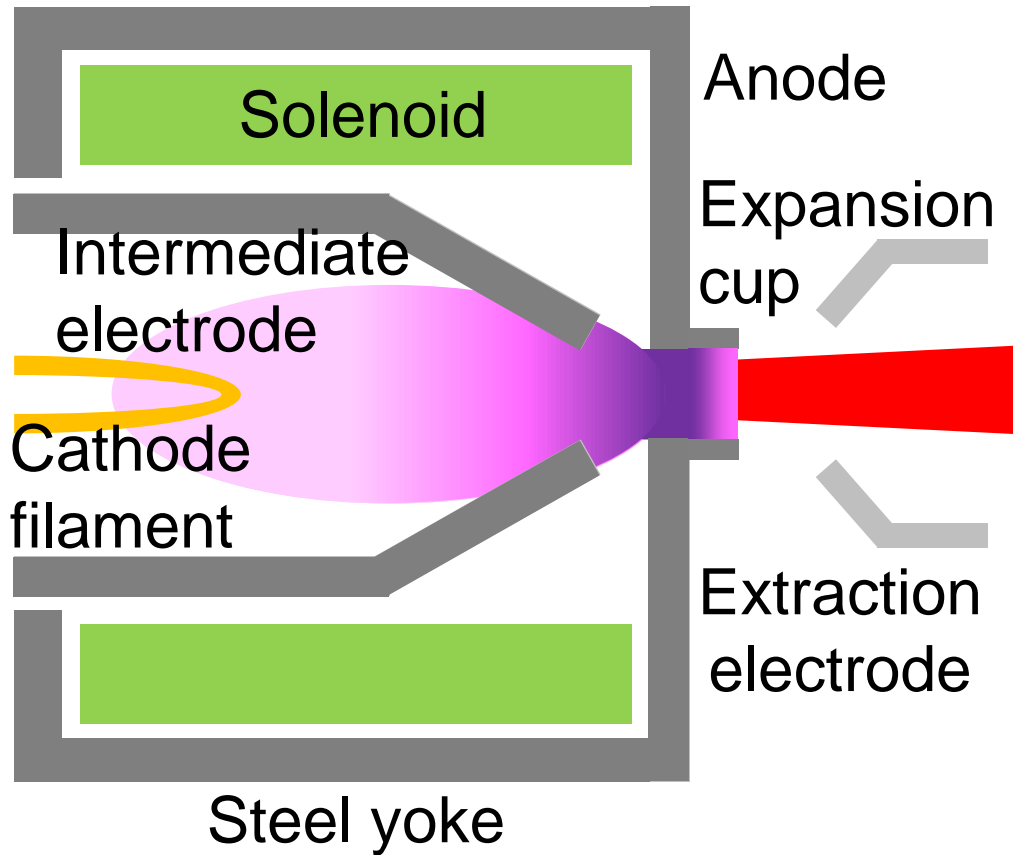
Beam ionises residual gas and traps electrons in beam potential: **Space charge compensation**. Takes  $\sim 50 \mu\text{s}$ , depending on vacuum pressure.

# Summary of Fundamentals (2)

- Most ion sources involve **plasma**
- Lots of **parameters** to describe a plasma
- Plasmas **confined** with various topology magnetic fields
- After plasma is the beam **extraction** region
- Plasma **meniscus** defines initial beam focussing
- **Space charge** affects low energy, high mass beams
- Often attempt deliberate space charge **compensation**
- Now we can move onto real examples of ion sources...

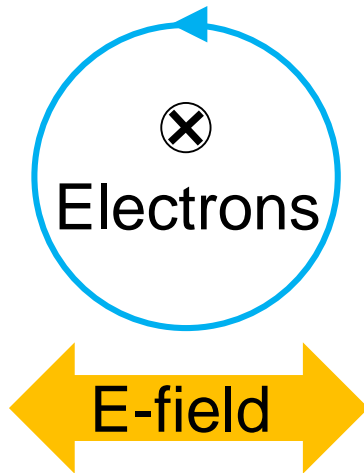
# Proton Sources

Duoplasmatron  
CERN Linac2 1956  
300 mA protons  
150  $\mu$ s, 1 Hz

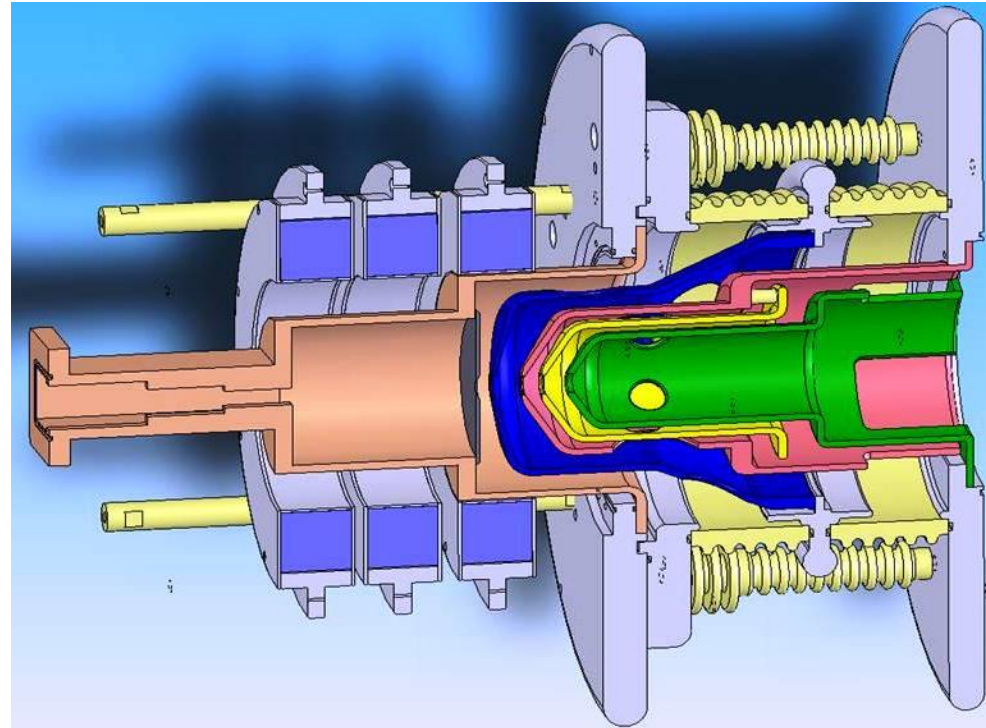


# Proton Sources

- RF cavity immersed in axial solenoid field
- Select RF frequency to match Larmor frequency
- Electrons gain energy
- Increases ionisation rate



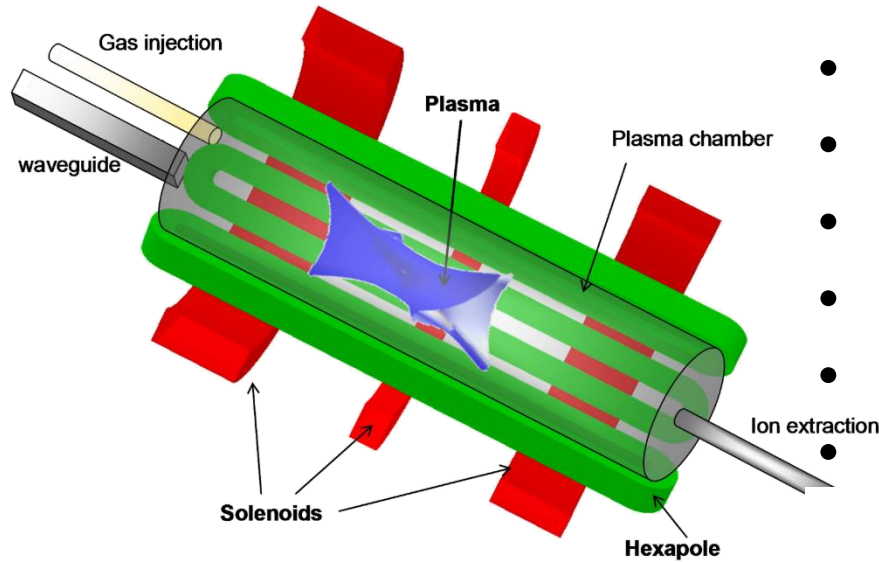
2.45 GHz ECR  
SILHI @ CEA, INFN, ESS...  
120 mA protons  
All duty factors up to 100%



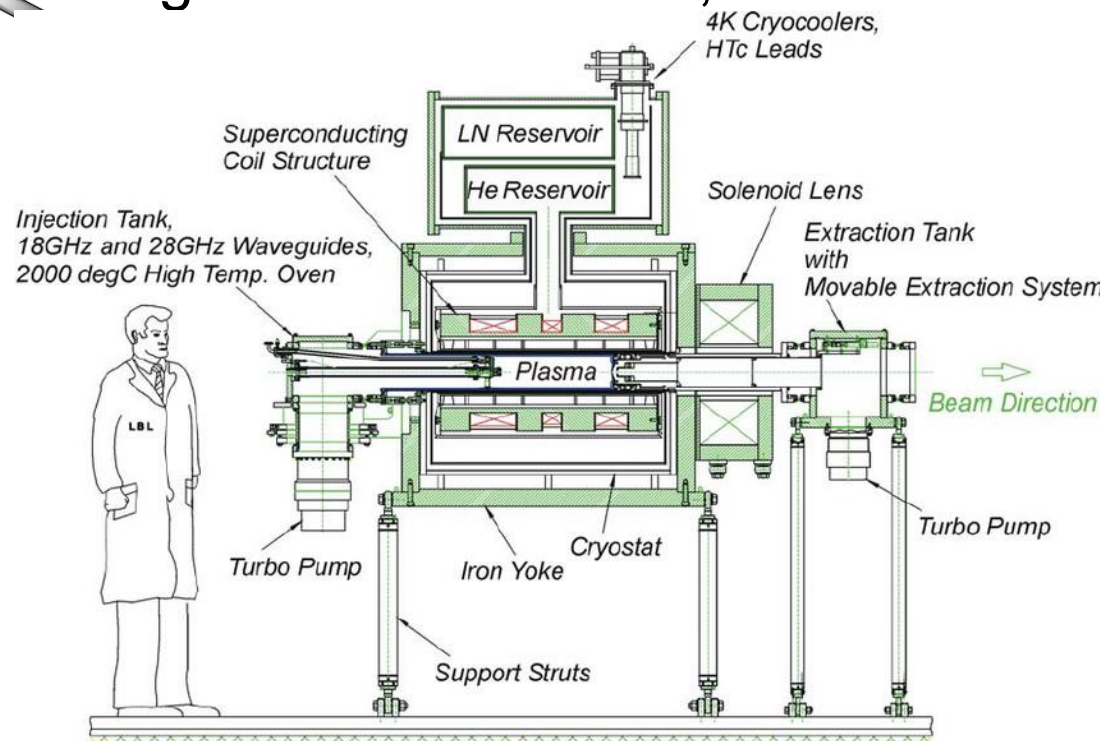
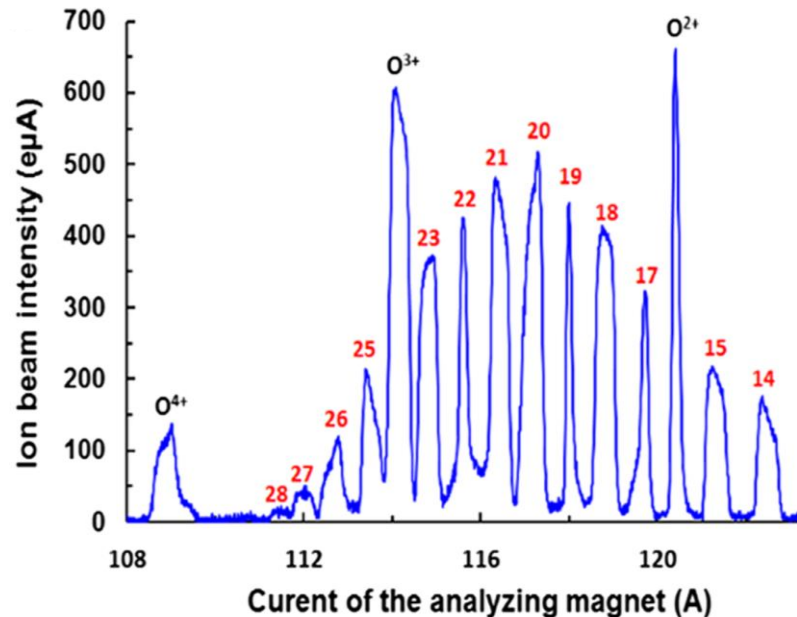
Electron Cyclotron Resonance (ECR)



# High Charge State Sources

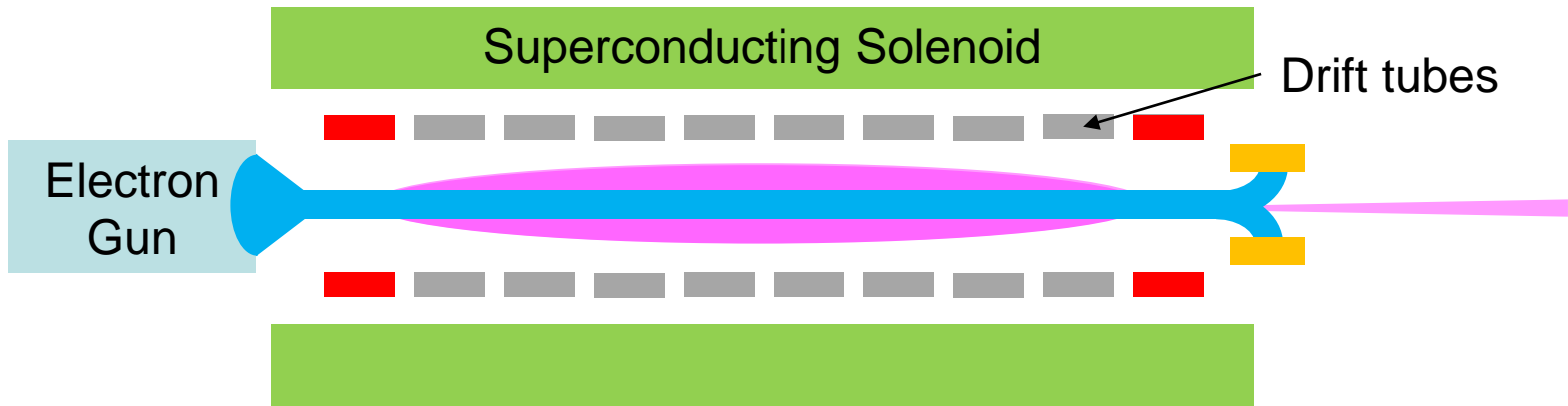


- Hexapole transverse confinement
- Higher frequency → stronger B
- Superconducting magnets
- Large and very expensive!
- SECRAL & VENUS 28 GHz ECRs
- High currents of  $\text{Bi}^{20+}$ ,  $\text{Pb}^{34+}$  ...



# High Charge State Sources

- High power electron beam ionises gas
- Ions trapped and undergo step-wise ionisation
- Remove trapping voltage to release ions



## Electron Beam Ion Source

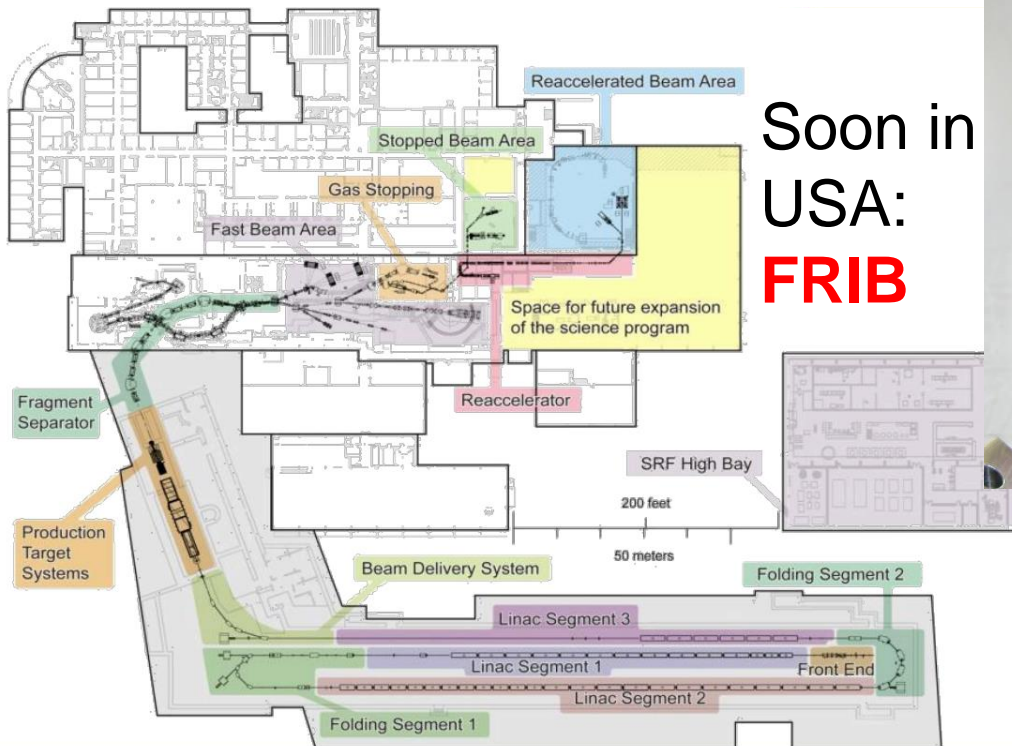
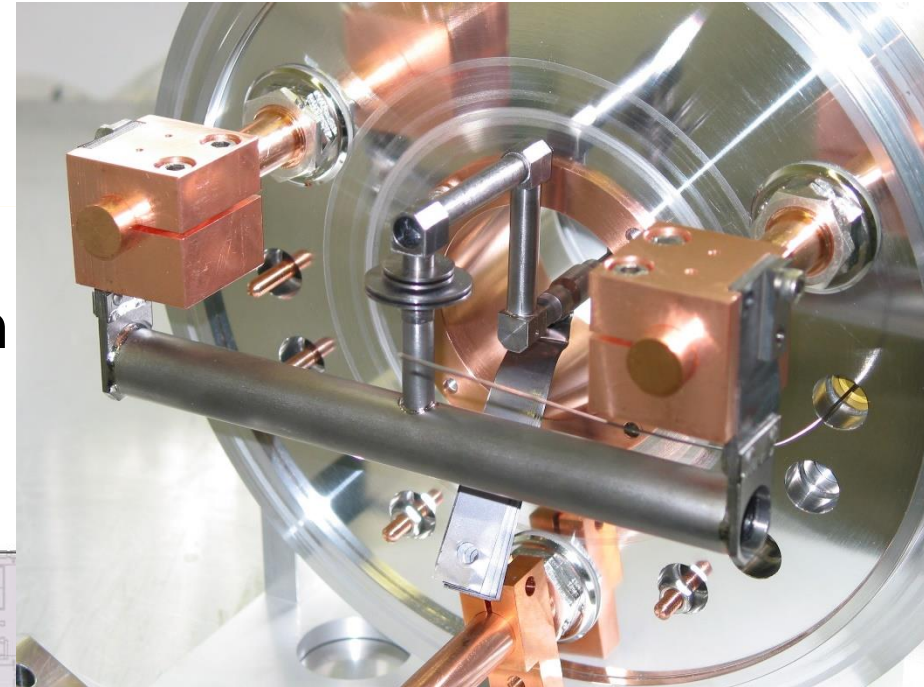
- EBIS @ RHIC
- 10 A electron gun
- 5 T, 1.9 m ion trap
- Au<sup>32+</sup>, U<sup>39+</sup> ...
- 10  $\mu$ s, 5 Hz pulses

# Charge Breeders & ISOL

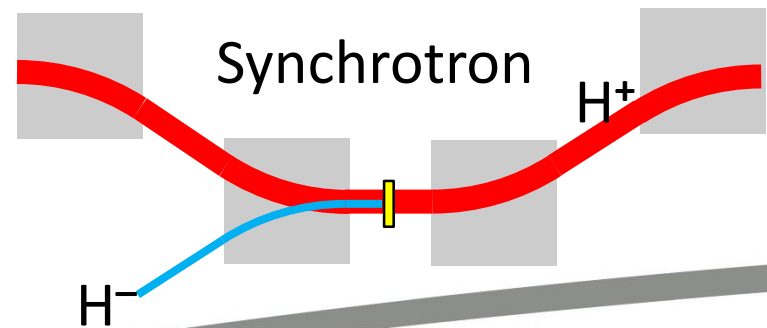
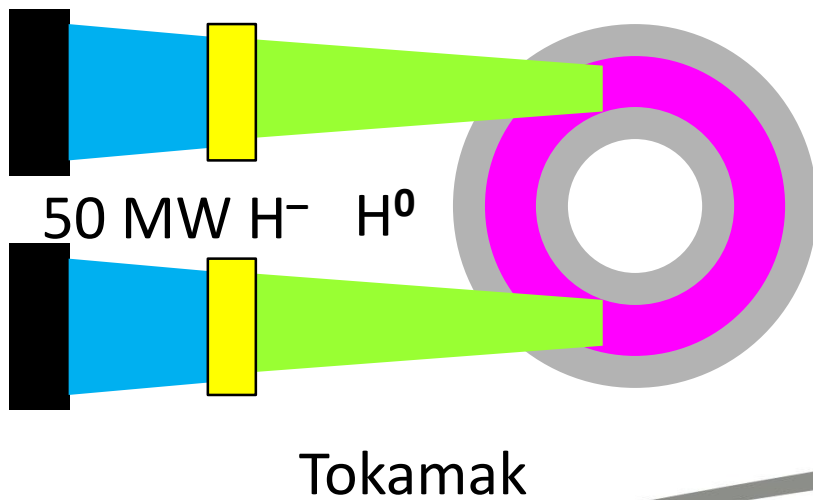
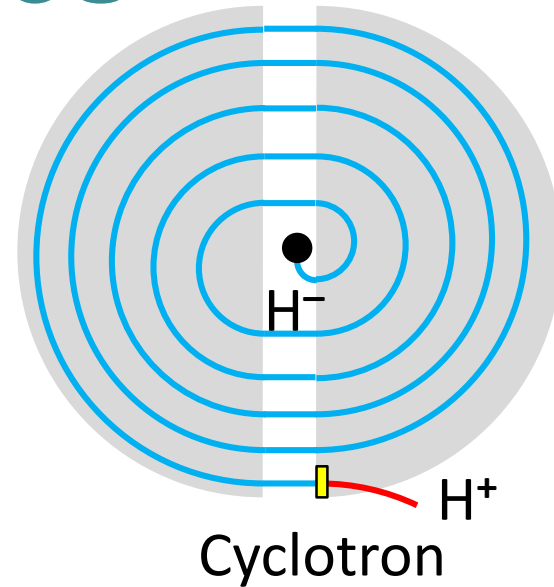
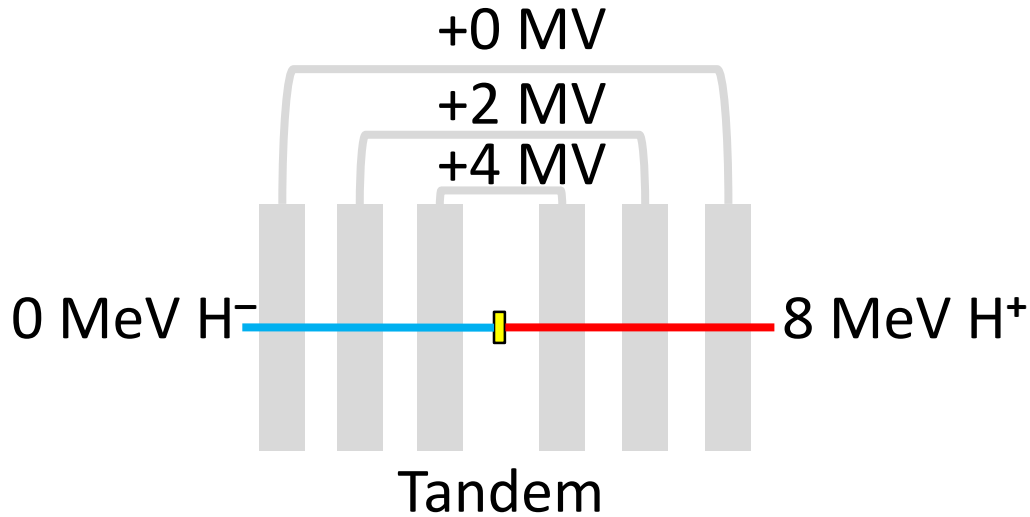
(Isotope Separation On-Line)

- Impact protons onto target
- Radioactive ions emerge
- Further ionisation in plasma
- Extract and (quickly!) accelerate and analyse
- Study very exotic nuclei

ISOLDE @ CERN  
 $10^7$   $^{132}\text{Sn}$  per second



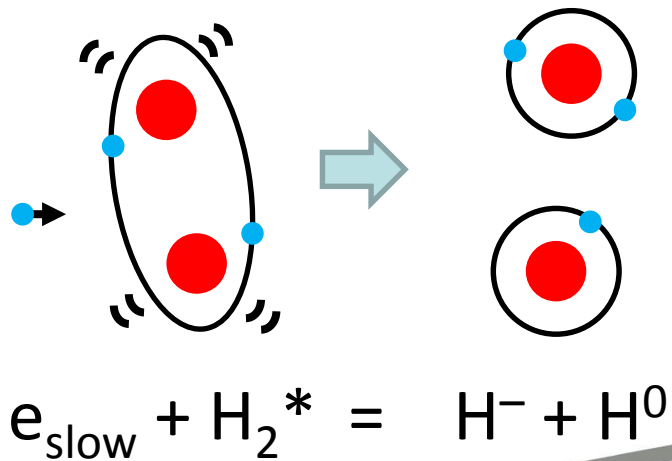
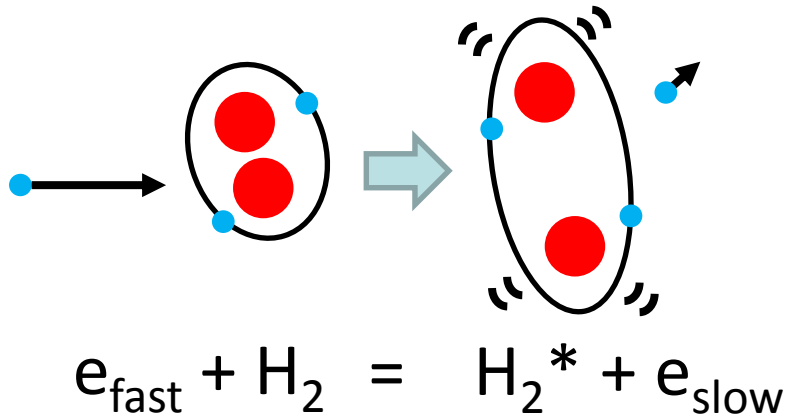
# Negative Ion Sources



# H<sup>-</sup> Ion Production Methods

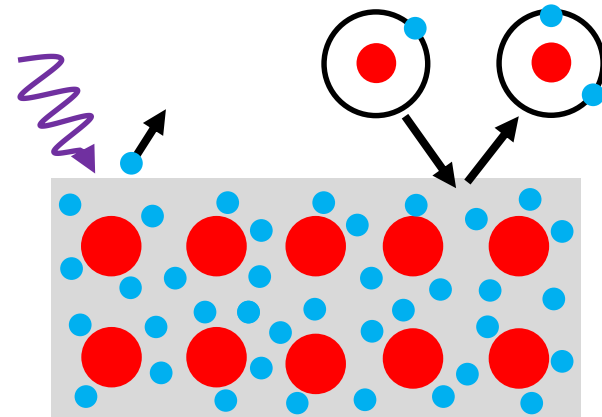
## Volume Production

(H<sup>-</sup> beams ≲ 40 mA)



## Surface Production

(H<sup>-</sup> beams ≳ 40 mA)



Low  $\phi_{\text{work}}$  metals release electrons

Alternatively, energetic atoms hitting surface can take a free electron, creating H<sup>-</sup>

# Caesium: a Blessing and a Curse

Good Points	Bad Points
<ul style="list-style-type: none"><li>• Allows copious <math>H^-</math> production</li><li>• Reduces co-extracted <math>e^-</math> current</li><li>• Allows high current plasma arc</li><li>• Stabilises plasma</li><li>• Nothing else as effective</li></ul>	<ul style="list-style-type: none"><li>• Increases rate of HV sparking</li><li>• Makes vacuum vessel messy</li><li>• Highly explosive AND toxic</li><li>• Hard to work with and expensive</li><li>• Reduces ion source lifetime</li></ul>

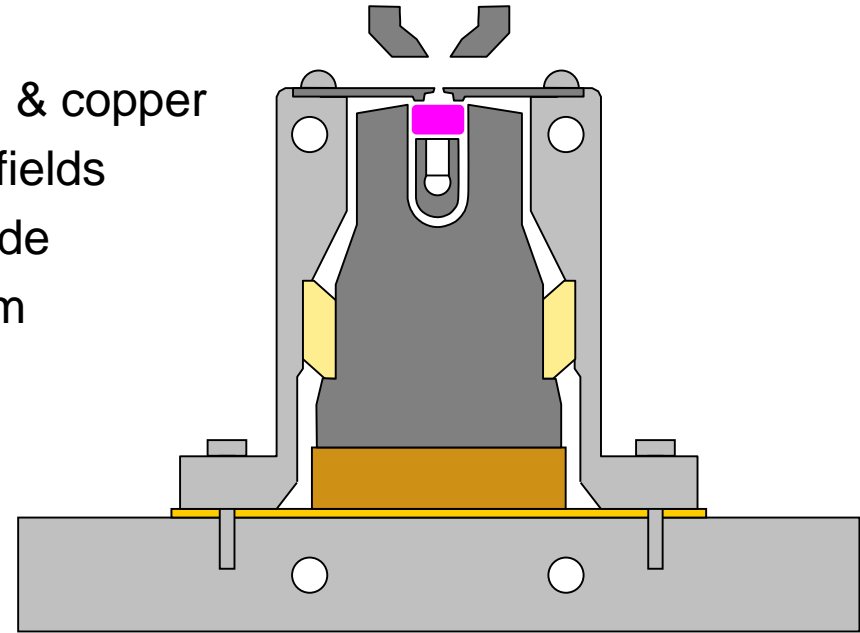


## Moral:

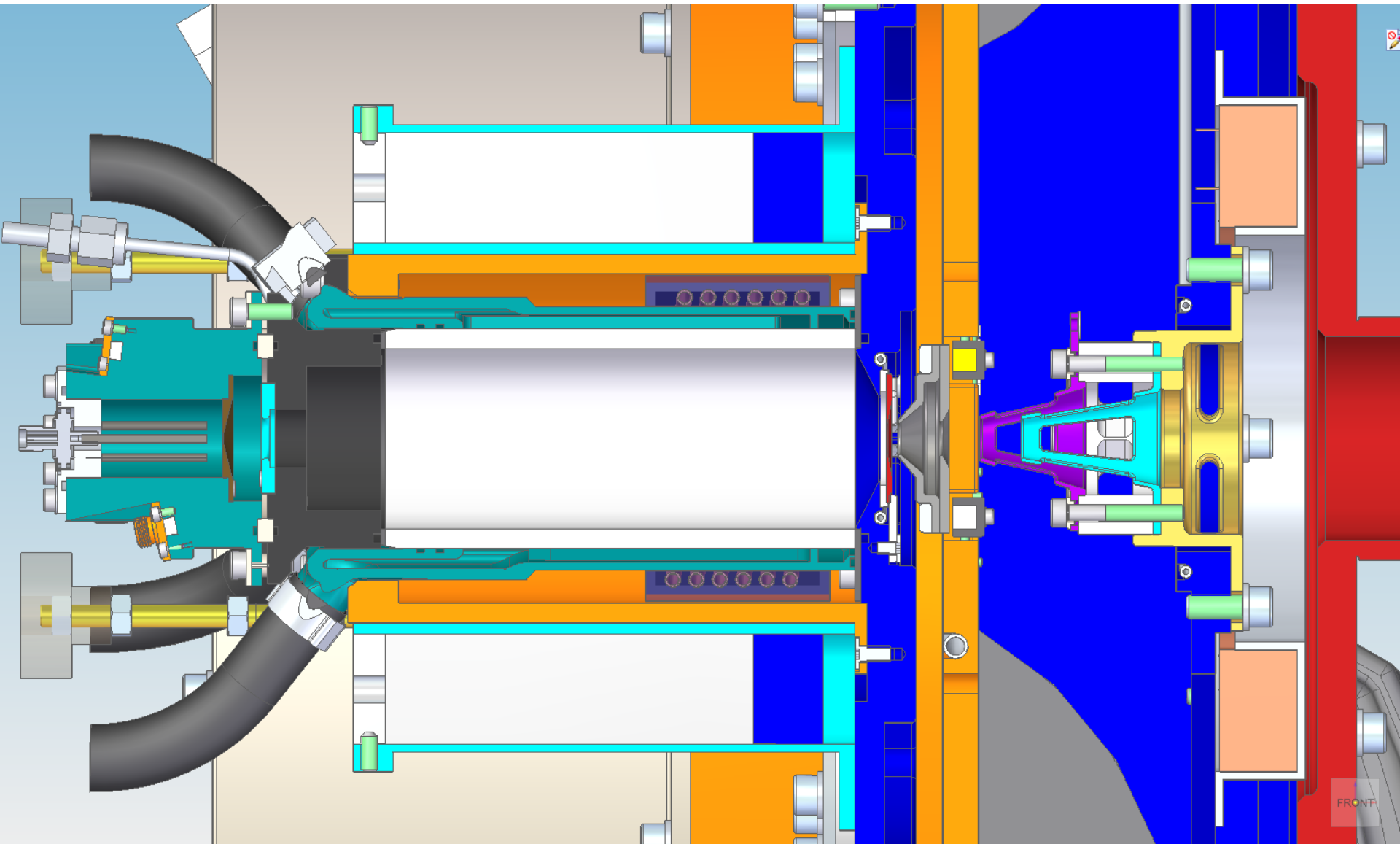
**Only use 'JUST ENOUGH'  
caesium for acceptable  
ion source performance!**

# ISIS Penning Surface H<sup>-</sup> Source

- Machined molybdenum, ceramic, stainless & copper
- High temperature and magnetic & electric fields
- Microscope alignment of extraction electrode
- Hydrogen & caesium feeds into the vacuum
- Welded 1/8" air & water cooling pipes
- Bolts torqued for good thermal contact
- > 2 kW of power damages components
- Lasts 3-4 weeks → have 10 ready to go
- 55 mA H<sup>-</sup> at 250 μs, 50 Hz



# ISIS RF Volume H- Source





# Final Thoughts

Accelerator designers always want more from the particle source!

**More current**

**Higher charge states**

**Higher duty factor**

**Lower emittance**

**Longer lifetime**

**More stability**

**Squarer pulse shape**

**More Gaussian Profile**

**Quicker start-up**

**Better vacuum**

**Very active & exciting career, always in need of more minds**

# Thank you for listening!

Feel free to contact me if you're interested in this subject.  
Please email homework answers to me by 22/03/2019.

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# Homework Questions

1. Use the ideal gas law to calculate the particle number density inside a room-temperature vacuum vessel at a (somewhat poor) pressure of  $10^{-4}$  mbar. Assuming  $\sigma_{en} = 6 \times 10^{-19} \text{ m}^2$ , calculate the mean free path. If the vessel is 0.5 m long, is the pressure high enough to be collisional?
2. You want to make an electron gun which can operate at 1 kHz, with an extracted charge of 500 pC/bunch. Your photocathode has Q.E. =  $1 \times 10^{-4}$ . What power laser would you need if it operated at a wavelength of 532 nm?
3. You want to make an  $\text{H}^-$  ion source with an output beam current of 40 mA at 45 kV extraction voltage operating at 50 Hz for the scSPS project.
  - a) Discuss whether you would use caesium in this ion source.
  - b) What are the benefits and drawbacks of altering the geometry terms  $A$  and  $\alpha^2$  to reach a suitable perveance?
  - c) Write a list and brief justification of the physics simulations you would need to perform to design this ion source.